

Quantum anomalous Hall effect in magnetic topological insulator

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Acknowledgement

MBE, STM, and ARPES

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Shuai-Hua Ji, Xi Chen, Xu-Cun Ma, and **Qi-Kun Xue**

Tsinghua-IOP

Transport

Jinsong Zhang, Zuo Cheng Zhang,
Minghua Guo, Yang Feng, and
Yayu Wang

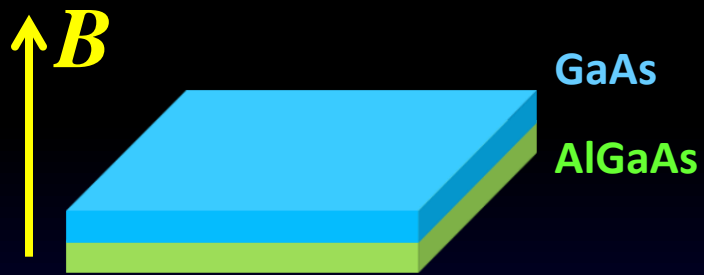
Tsinghua

Jie Shen, Zhong-Qing Ji, and **Li Lu**
IOP

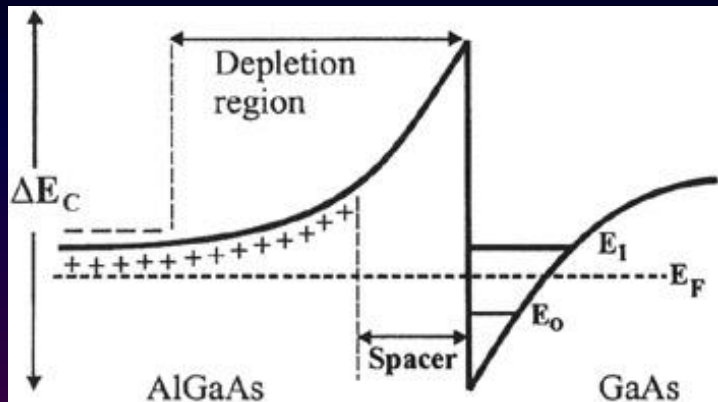
Theory & Calc.

Xi Dai, Zhong Fang
IOP

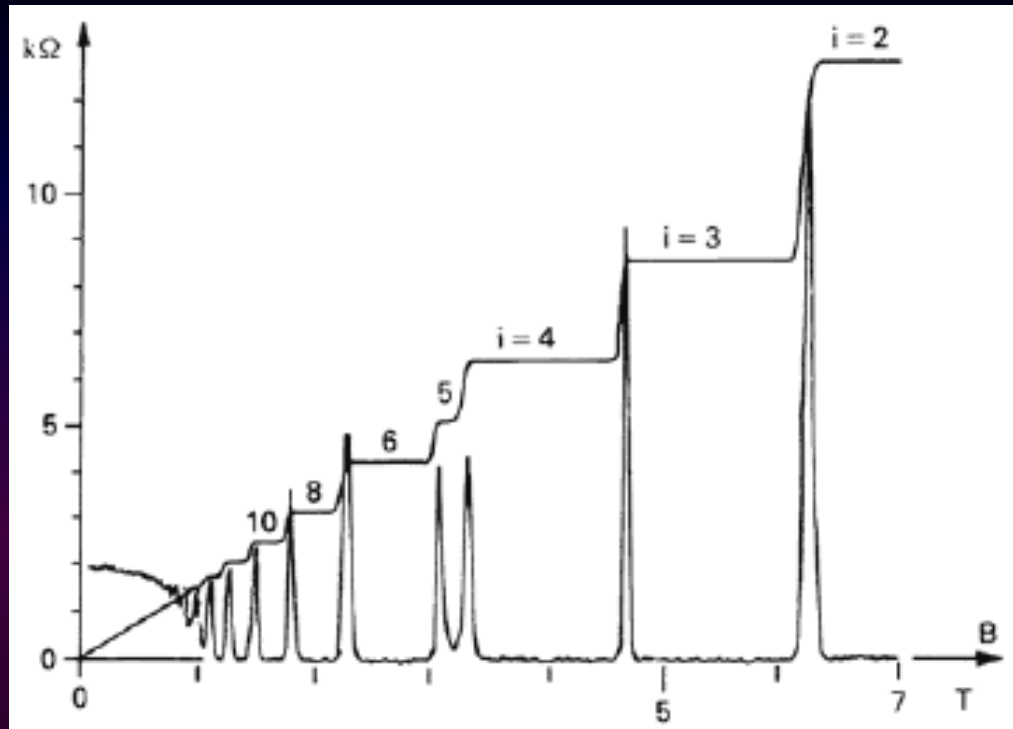
X.-L. Qi, S.-C. Zhang
Stanford



Quantum Hall Effect



Two dimensional electron gas



**Klaus
Von
Klitzing**

$$\rho_{yx} = h / ie^2$$

$$\rho_{xx} = 0$$

Topological origin of QHE

$$\chi = 2$$



$$\chi = 0$$



$$\frac{1}{2\pi} \oint_S K dA = \chi$$

K : Gauss curvature

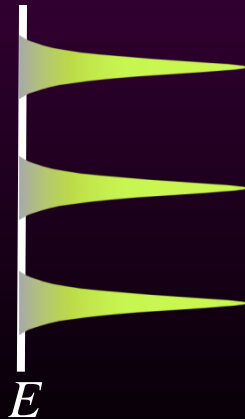
χ : Euler characteristic

Gauss-Bonnet Theorem

$$C = 0$$



$$C = 1$$

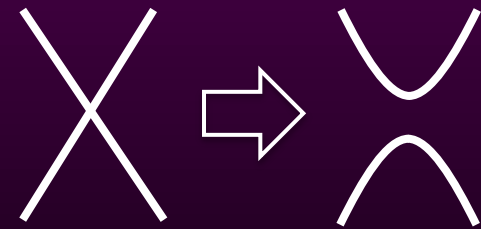
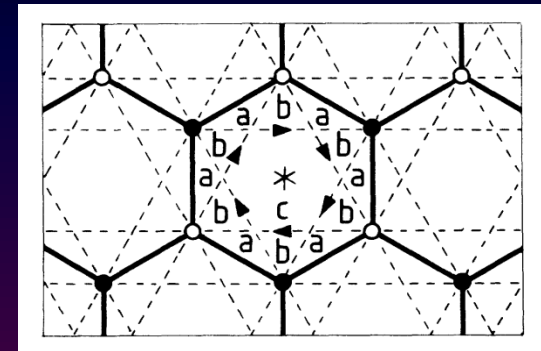
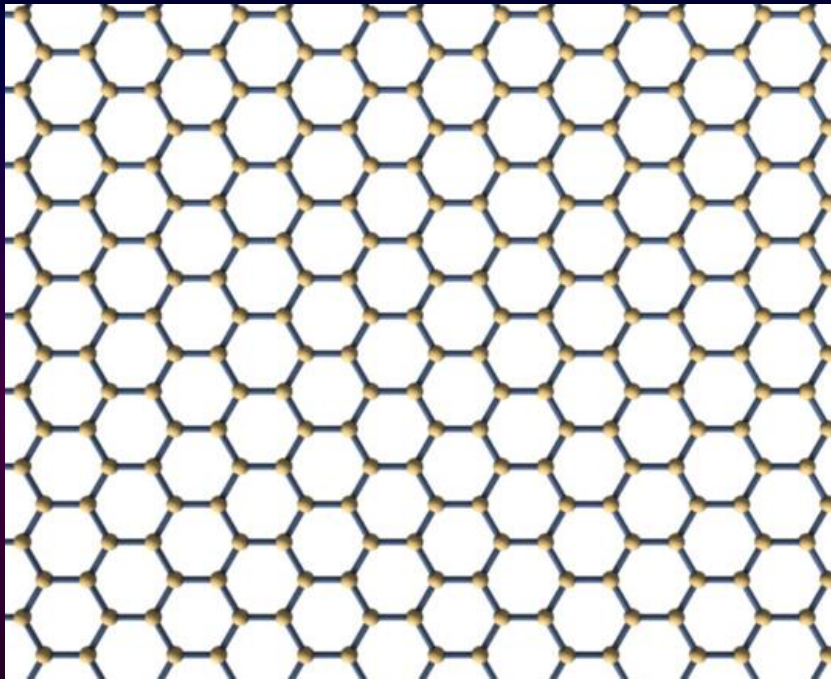


$$\frac{1}{2\pi} \oint_{BZ} \Omega d\vec{k} = C$$

Ω : Berry curvature

C : Chern number

Can we obtain QHE without Landau levels?



Graphene with periodic magnetic field but without net flux

Quantized AHE

Extrinsic: induced by impurities

Skew scattering

Smit, Physica 1958

Side jump

Berger, PRB 1970

Intrinsic: induced by energy band

Karplus & Luttinger, Phys. Rev. 1954

$$\sigma_{xy} = \frac{e^2}{h} \sum_{\text{occupied}} \frac{1}{2\pi} \oint_{\text{BZ}} \Omega d\vec{k}$$

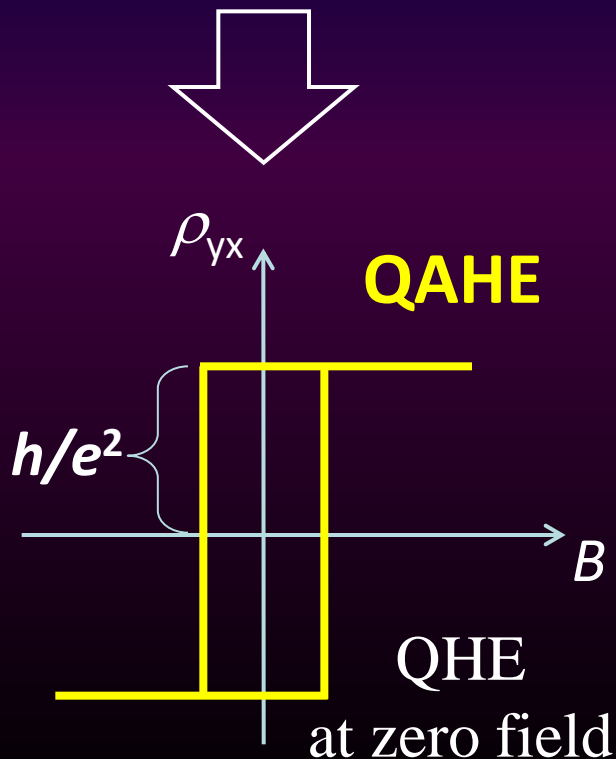
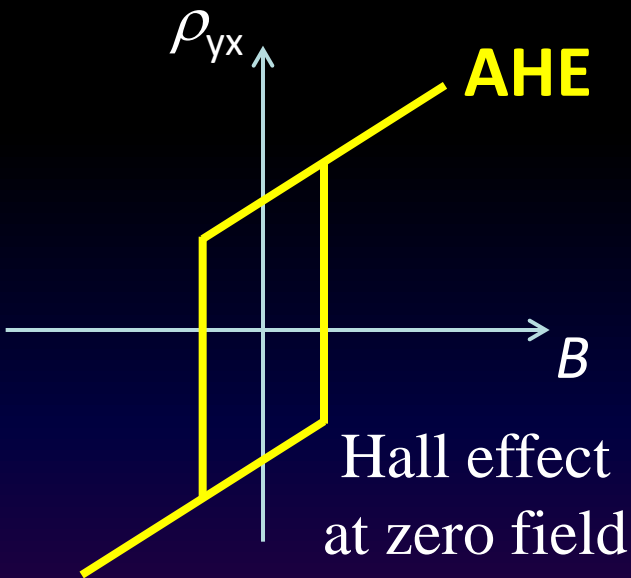
Chang & Niu PRB 1996, Sundaram & Niu

PRB 1999, Fang et al., Science 2003

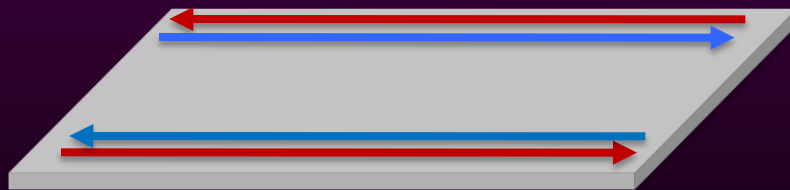
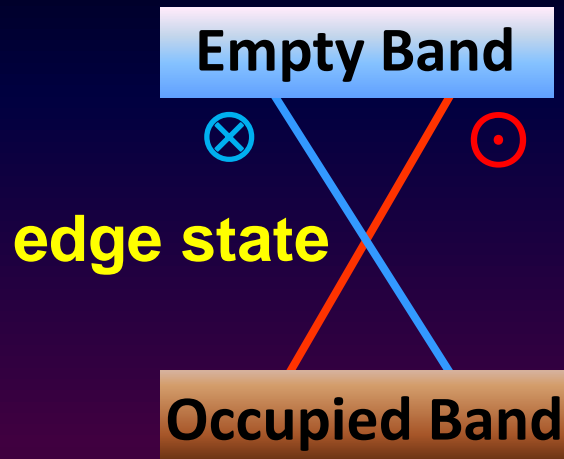
can be quantized in a ferromagnetic insulator with $C \neq 0$ (Chern insulator)

Onoda & Nagaosa, PRL 2003

Onoda, Sugimoto & Nagaosa, PRL 2006



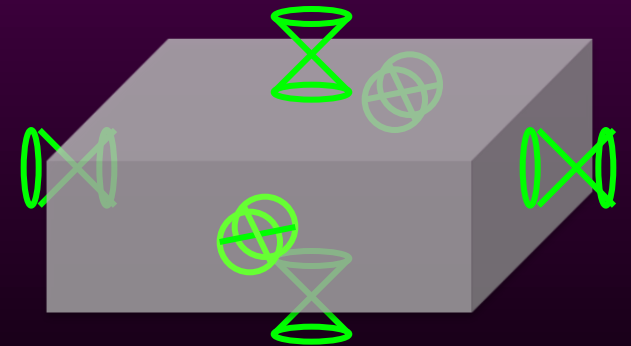
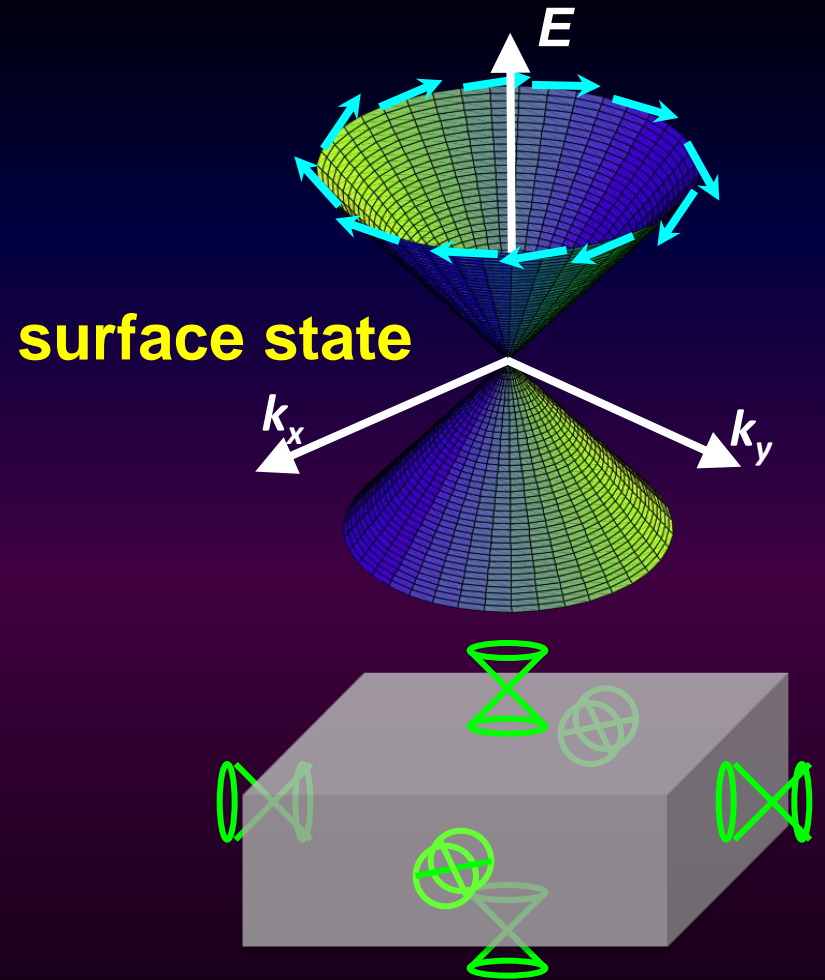
TRS Invariant Topological Insulators



2D TI (Quantum Spin Hall effect)

Mele & Kane, PRL 2005

Bernevig & Zhang, PRL 2006

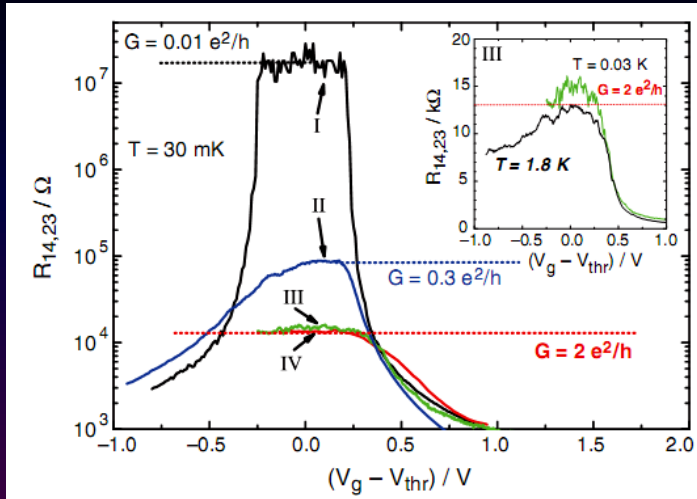


3D TI

Fu, Kane, & Mele, PRL 2007

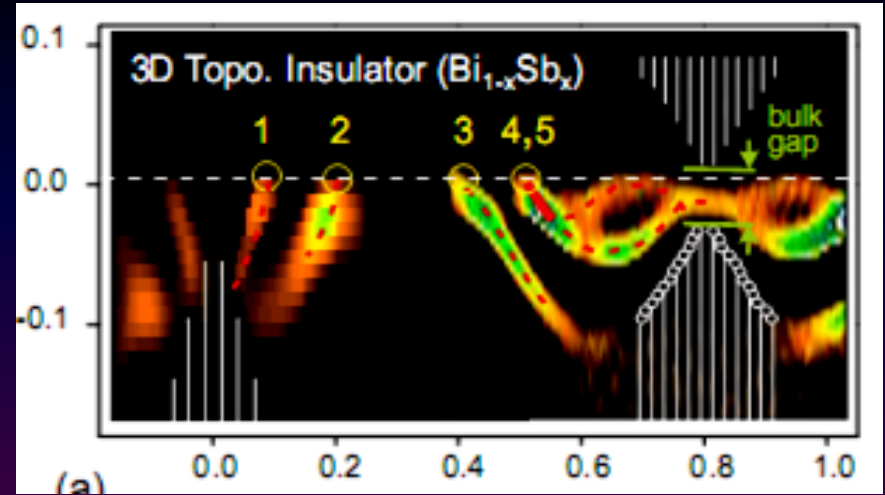
Real TI Materials

2D TI: HgTe Quantum Well

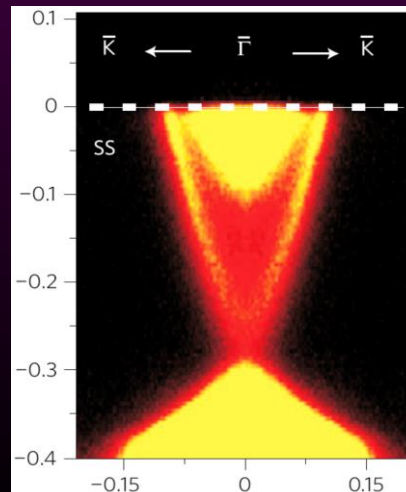
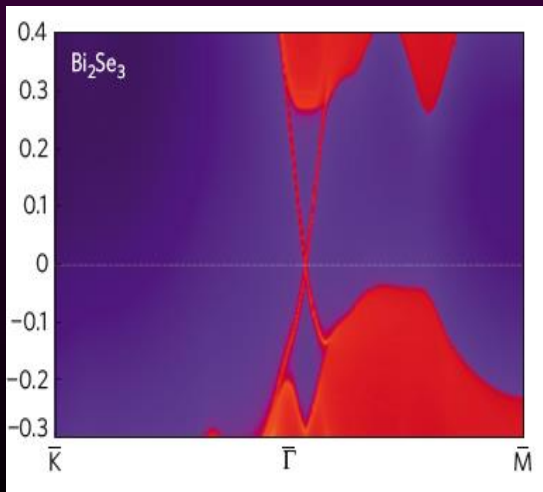


Bernevig, Hughes & Zhang, Science 2006
 König et al., Science 2007

3D TI: $\text{Bi}_{1-x}\text{Sb}_x$



Fu & Kane Phys. Rev. B 2007
 Hsieh et al., Nature 2008



H. Zhang et al.,
 Nature Phys. 2009

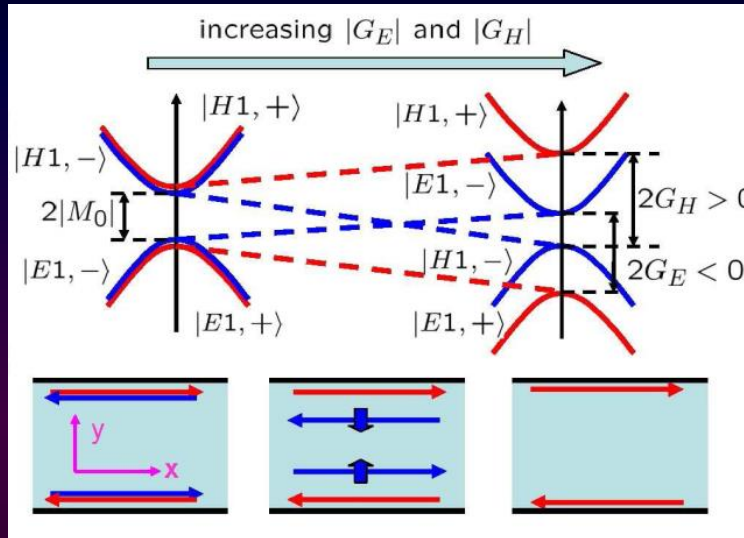
Y. -L. Chen et al.,
 Science 2009

Y. Xia et al., Nature
 Phys. 2009

**3D TI: Bi_2Se_3
 Family
 (Bi_2Se_3 ,
 Bi_2Te_3 ,
 Sb_2Te_3 ,)**

QAHE in magnetic TIs

2D TI

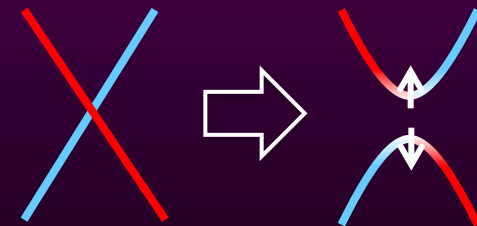
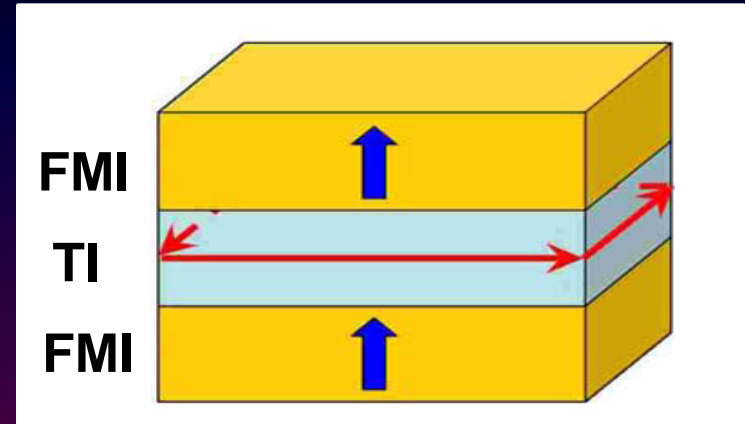


X. -L. Qi, Y. S. Wu & S. -C. Zhang,
PRB 2006

C. -X. Liu et al., PRL 2008

R. Yu et al., Science 2010

3D TI



X. -L. Q & S. -C. Zhang, PRL 2008

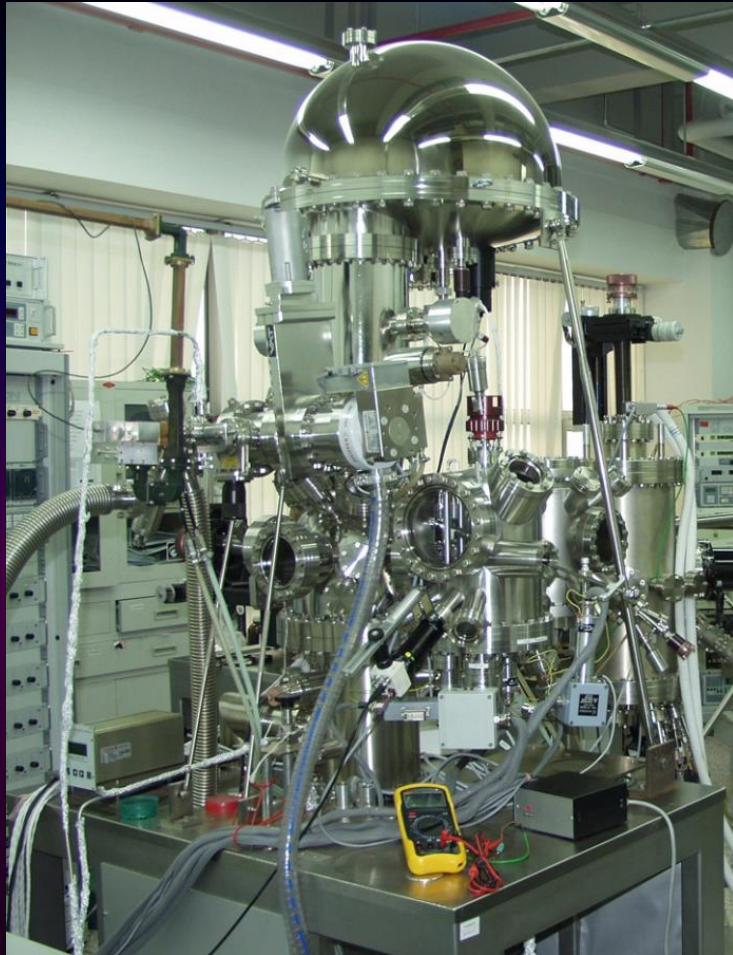
K. Nomura & N. Nagaosa, PRL 2011

To observe QAHE in a TI

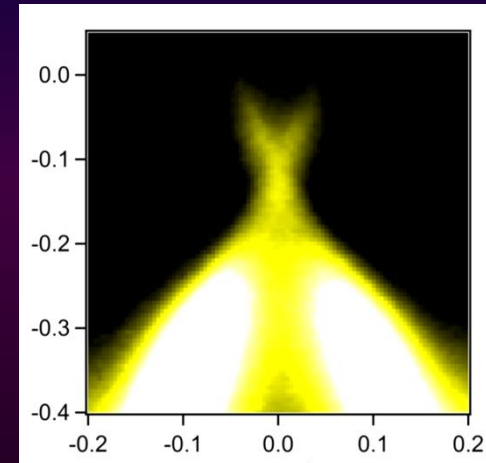
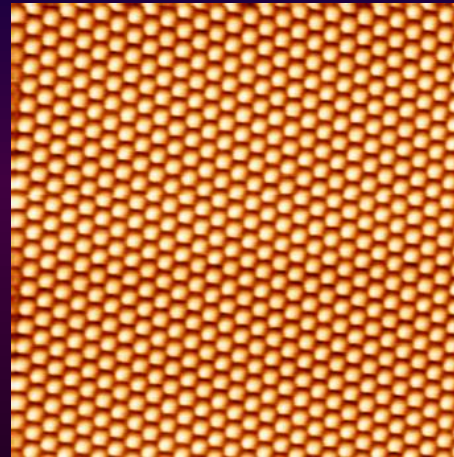
- Thin film with appropriate thickness
 - MBE growth
- FM insulator phase with perpendicular magnetic anisotropy
 - Magnetic doping
- Tunable chemical potential (carriers)
 - Chemical doping
 - Field effect

MBE-STM-ARPES Combo System

Omicron



MBE: Sample preparation
ARPES: Band structure
STM: Atomic arrangement



@ Qi-Kun Xue's group Tsinghua-IOP

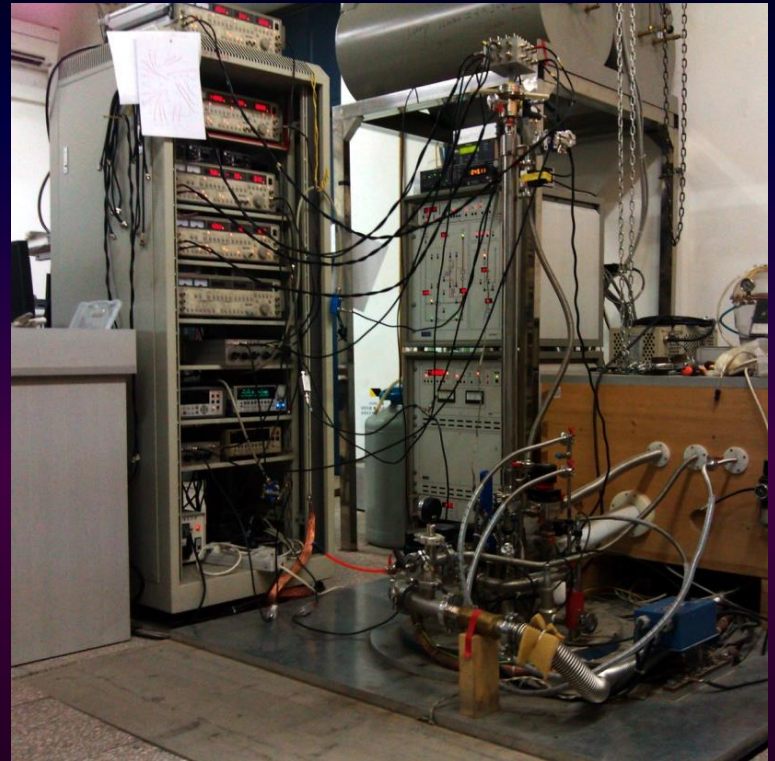
Facility for Transport Experiments

Oxford



250 mK, 15 Tesla

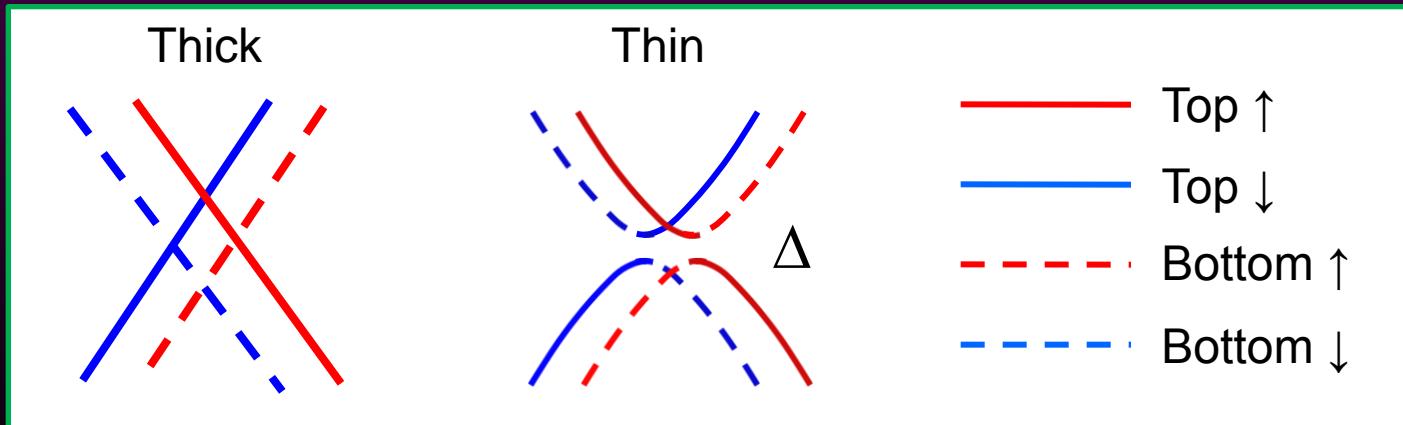
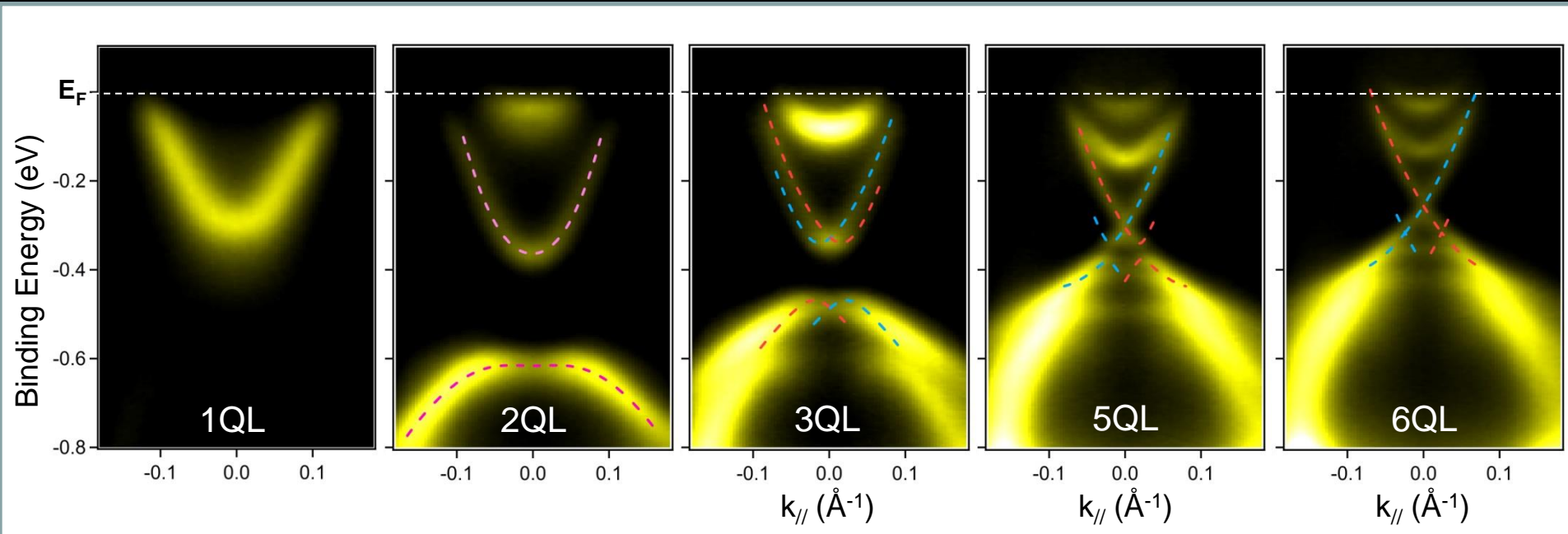
@ Yayu Wang's Group
(Tsinghua)



30 mK, 18 Tesla

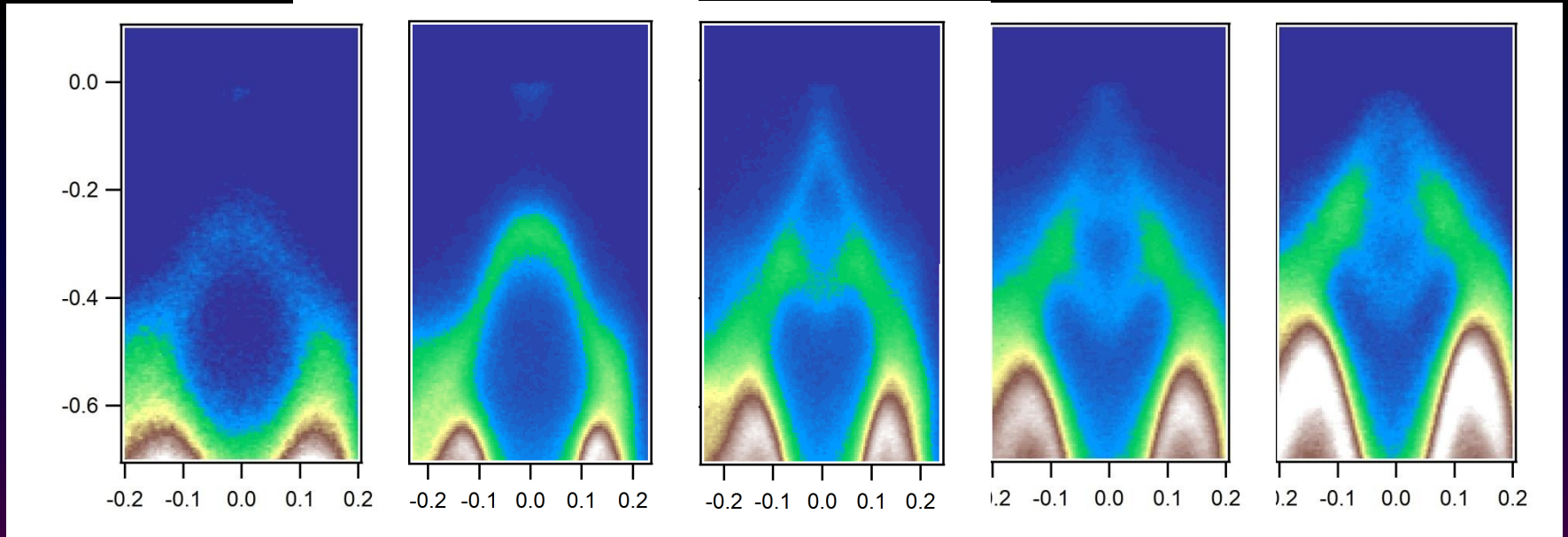
@ Li Lu's Group
(IOP)

MBE-grown Bi_2Se_3 thin films

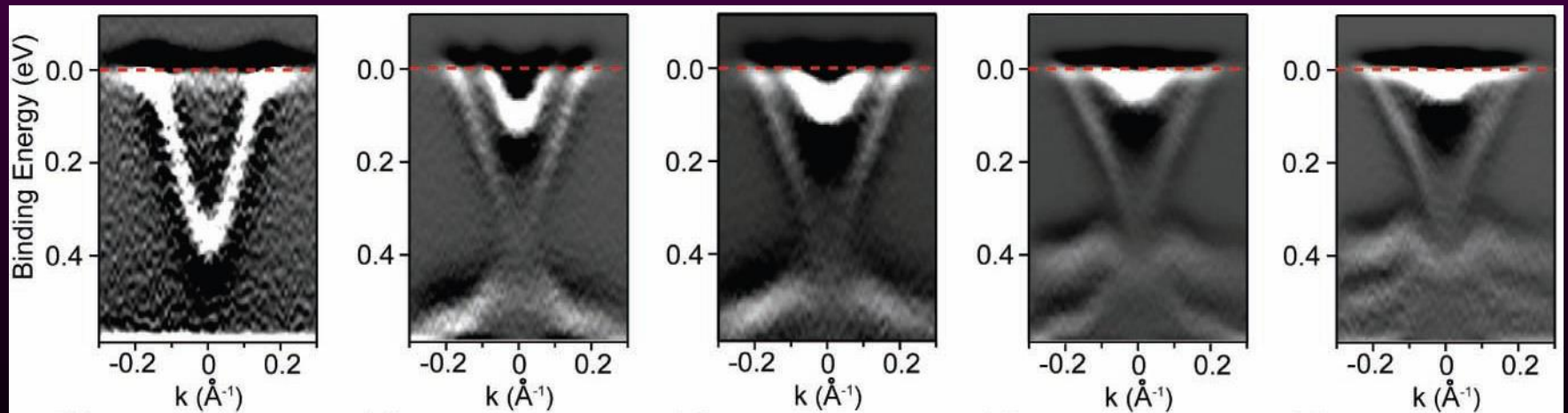


For QAHE,
 $\Delta < E_{\text{exchange}}$

MBE-grown Sb_2Te_3 and Bi_2Te_3 thin films

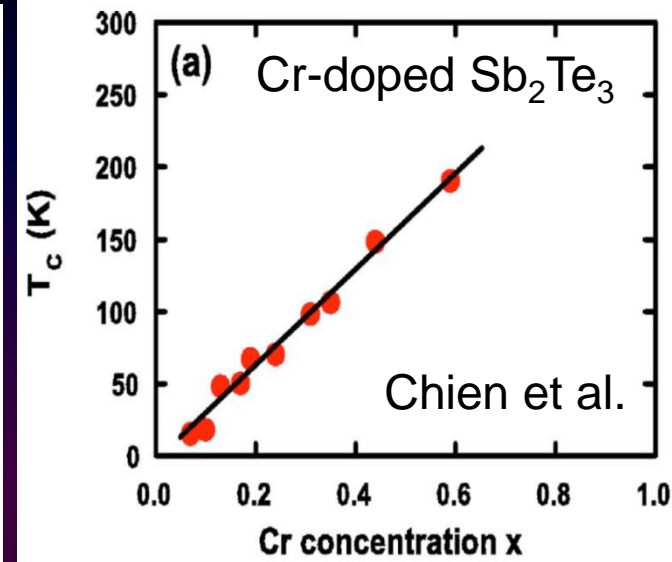
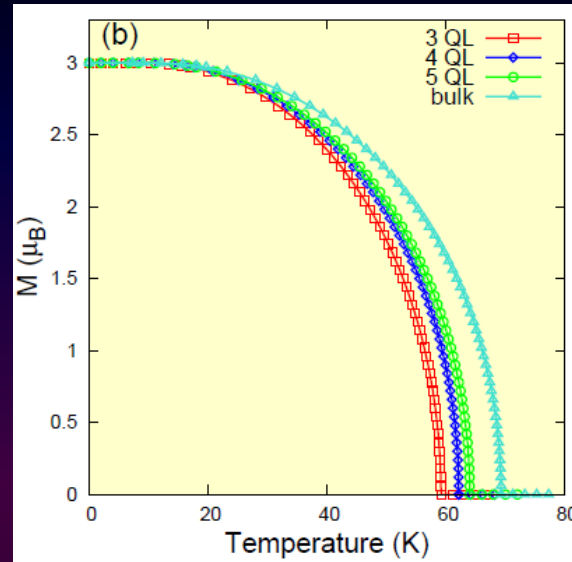
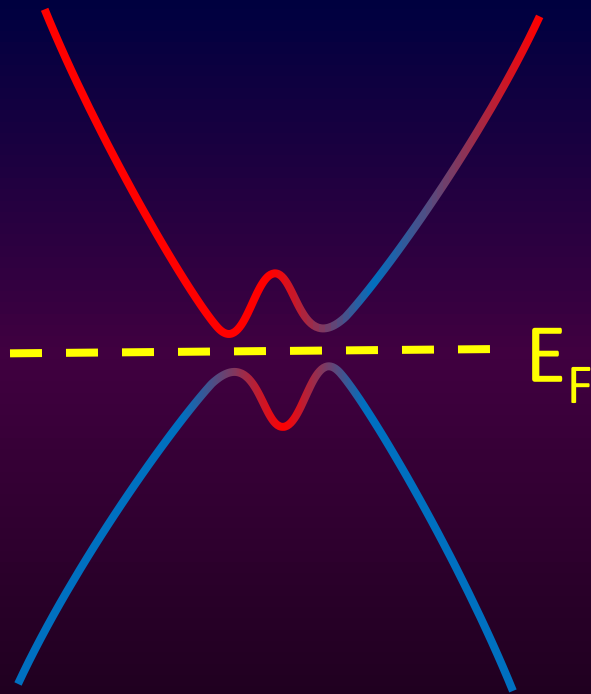


G. Wang et al., Nano Res. 3, 874 (2010).



Y. -Y, Li et al., Adv. Mater. 22, 4002 (2010).

Magnetically doped Bi_2Se_3 family TIs: FM of van Vleck mechanism



R. Yu et al., Science
329, 61 (2010).

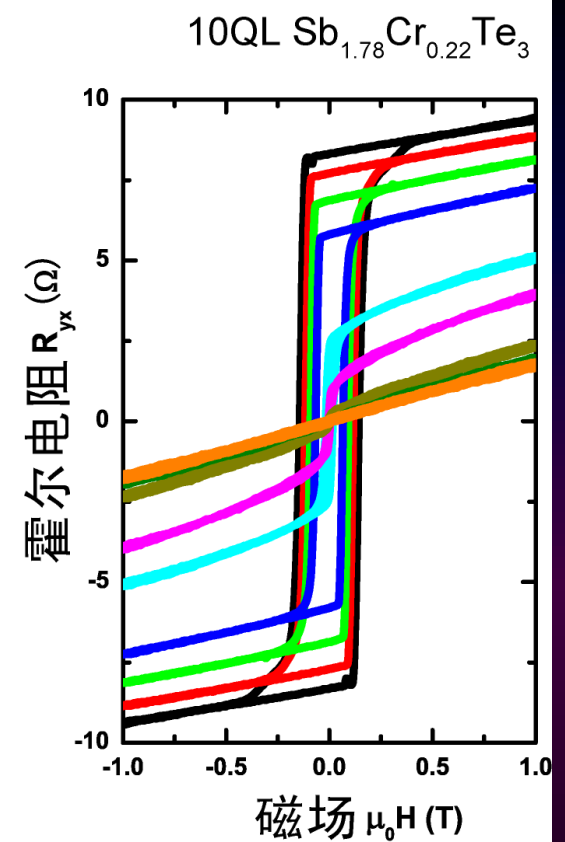
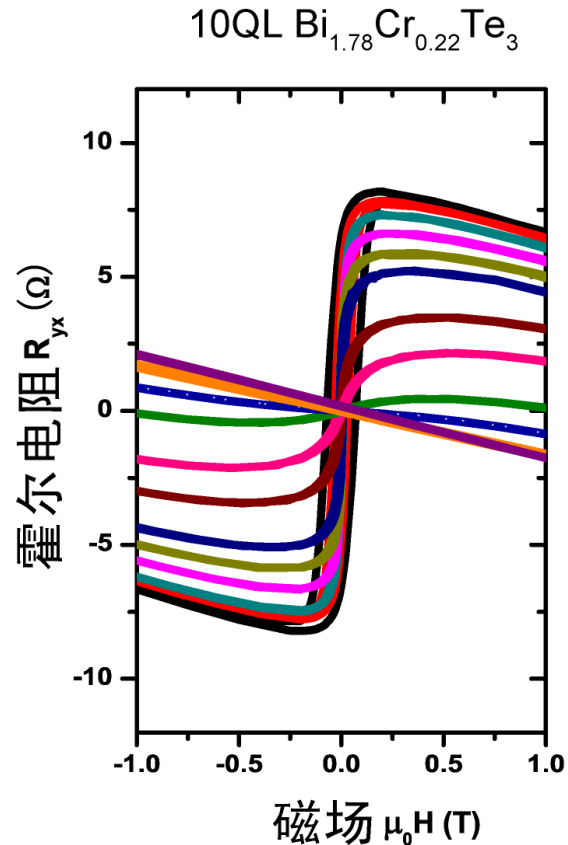
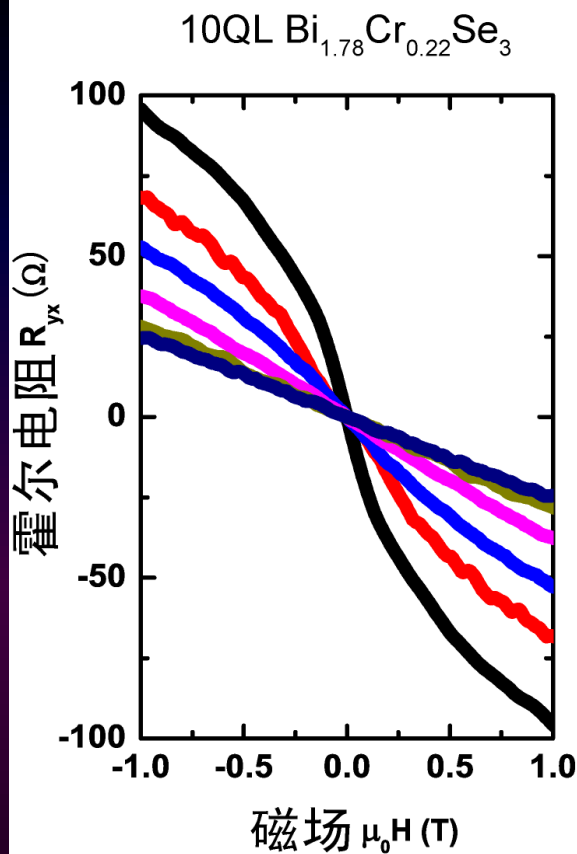
$$F_{\text{total}} = \frac{1}{2}\chi_L^{-1}M_L^2 + \frac{1}{2}\chi_e^{-1}M_e^2 - J_{\text{eff}}M_LM_e - (M_L + M_e)H$$

$$J_{\text{eff}}^2 - \chi_L^{-1}\chi_e^{-1} > 0$$

$$\chi_L = x\mu_J^2/(3k_B T)$$

$$\chi_e^{zz} = \sum_{E_{nk} < \mu; E_{mk} > \mu} 4\mu_0\mu_B^2 \frac{\langle nk | \hat{S}_z | mk \rangle \langle mk | \hat{S}_z | nk \rangle}{E_{mk} - E_{nk}}$$

Cr-doped Bi_2Se_3 group TIs



**No long range
FM order**

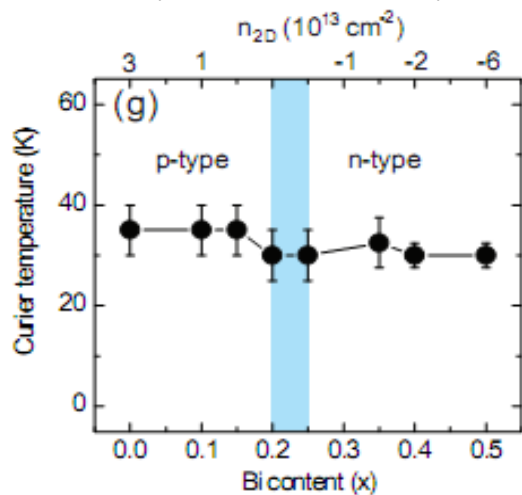
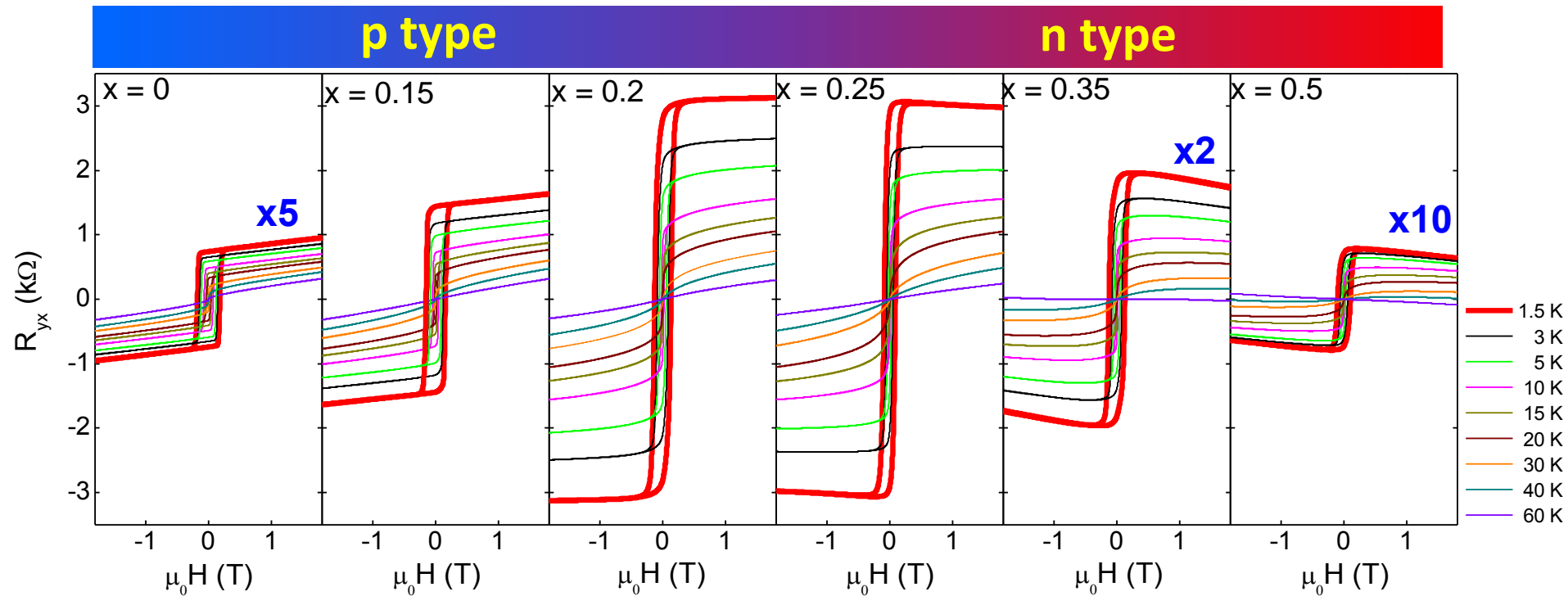
Long range FM order

M. Liu et al., PRL 108, 036805 (2012)

J. Zhang et al., Science 339, 1582 (2013)

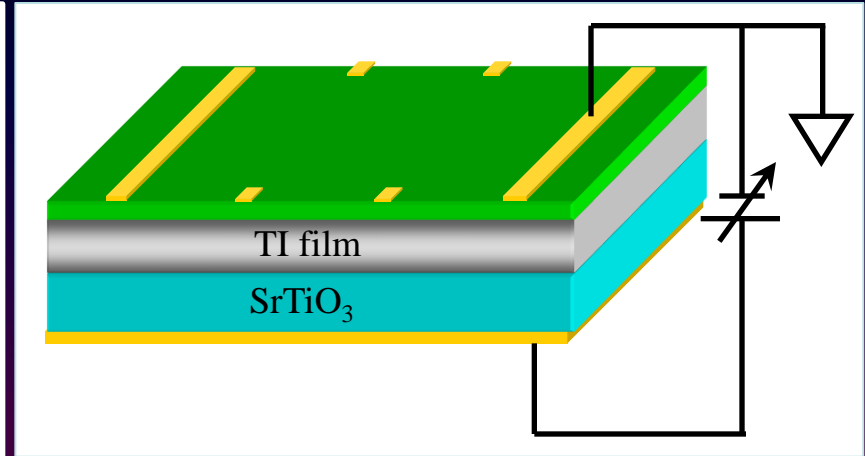
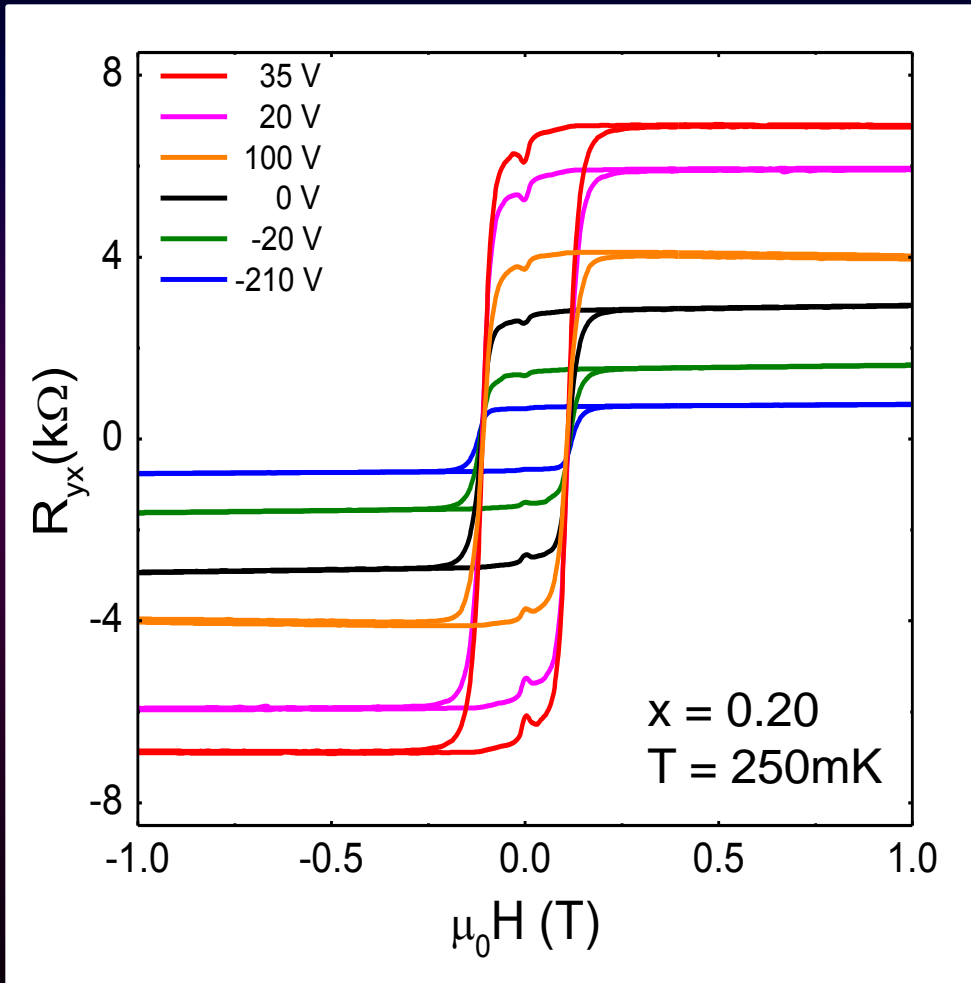
C. -Z. Chang et al., PRL 112, 056801 (2014)

Magnetism of $\text{Cr}_{0.22}(\text{Bi}_x\text{Sb}_{1-x})_2\text{Te}_3$



**Long-range ferromagnetic order
independent of carriers
(probably van Vleck-type)**

Gate-doping $\text{Cr}_{0.22}(\text{Bi}_x\text{Sb}_{1-x})_{1.78}\text{Te}_3$ film with SrTiO_3 substrate



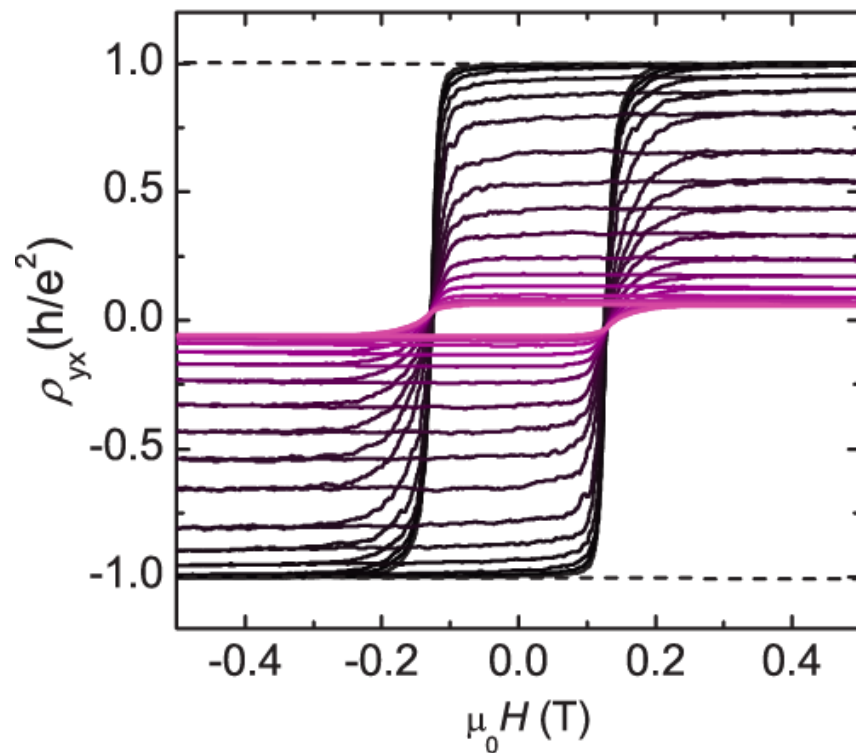
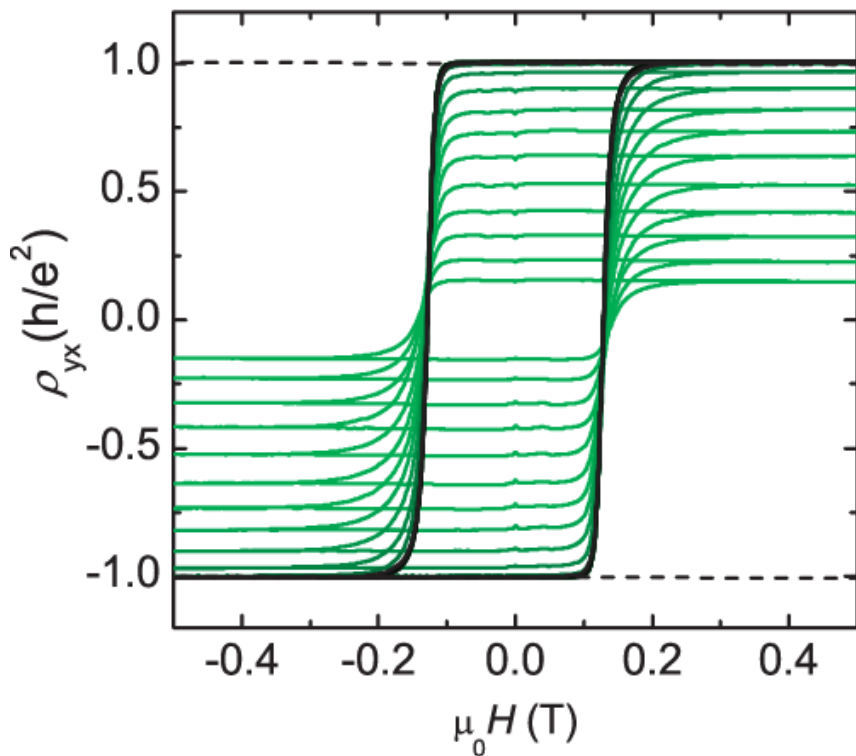
- FM order is little influenced
- ρ_{yx} up to $\frac{1}{4} h/e^2$

C. -Z. Chang et al., Adv. Mater. 25, 1065 (2013).

After one and half a year...

ρ_{yx} -B at different gate voltages

5QL $\text{Cr}_{0.15}(\text{Bi}_x\text{Sb}_{1-x})_{1.85}\text{Te}_3$ on SrTiO_3 (111)

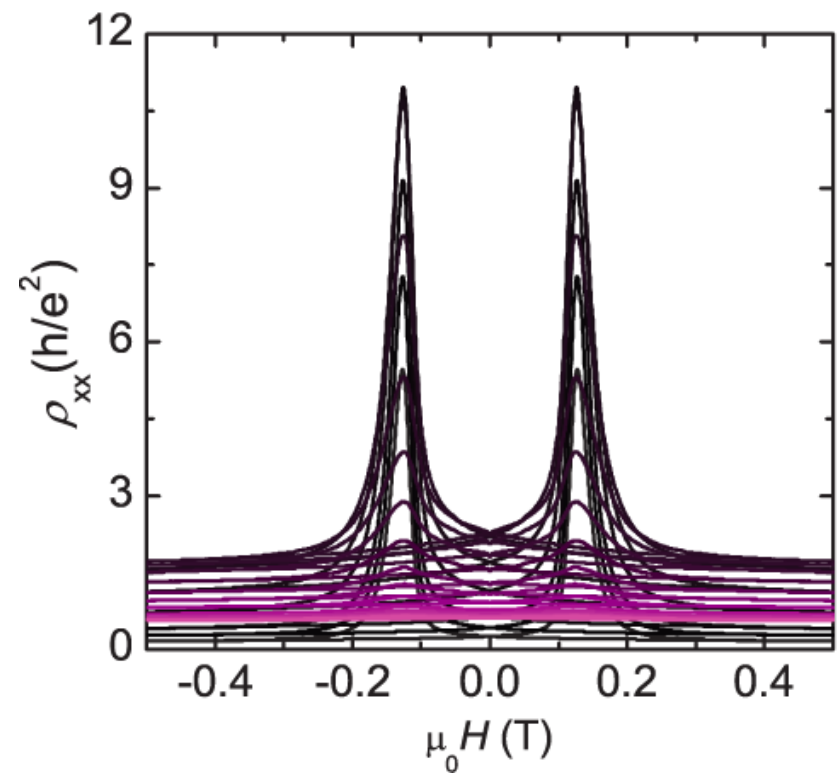
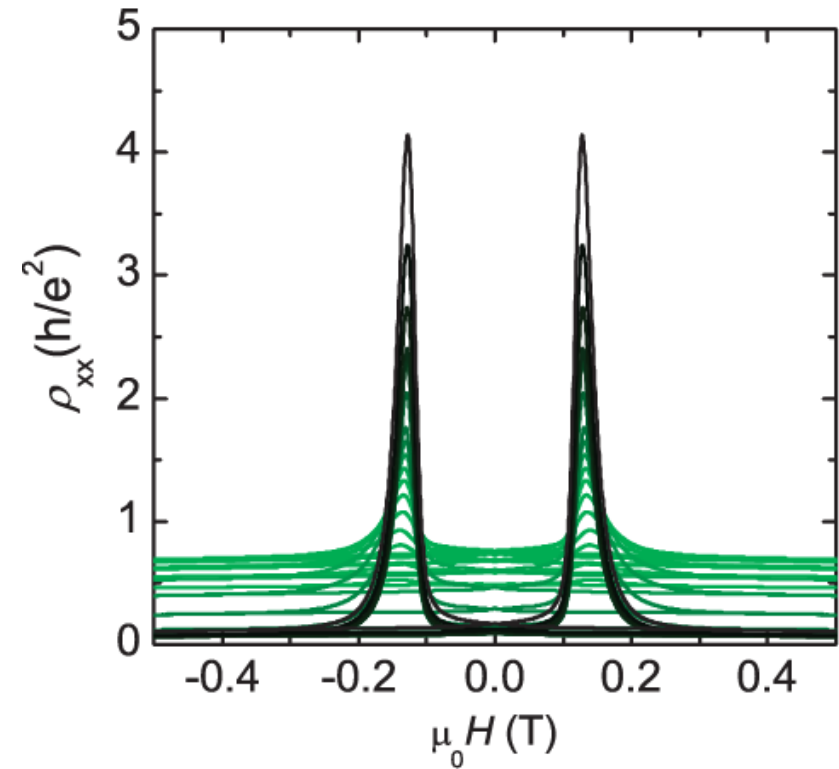


-55 V

0 V

220 V

ρ_{xx} -B at different gate voltages



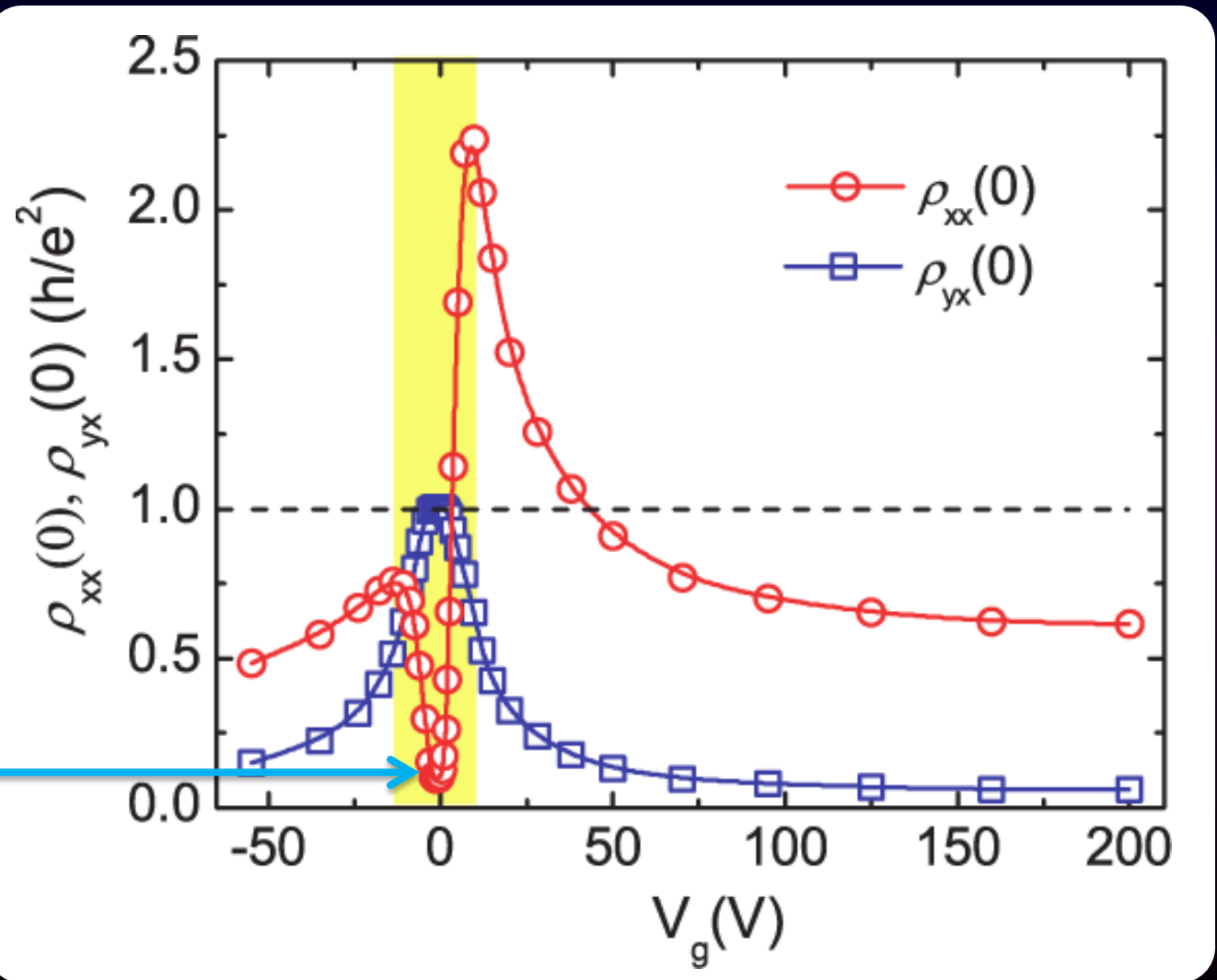
-55 V

0 V

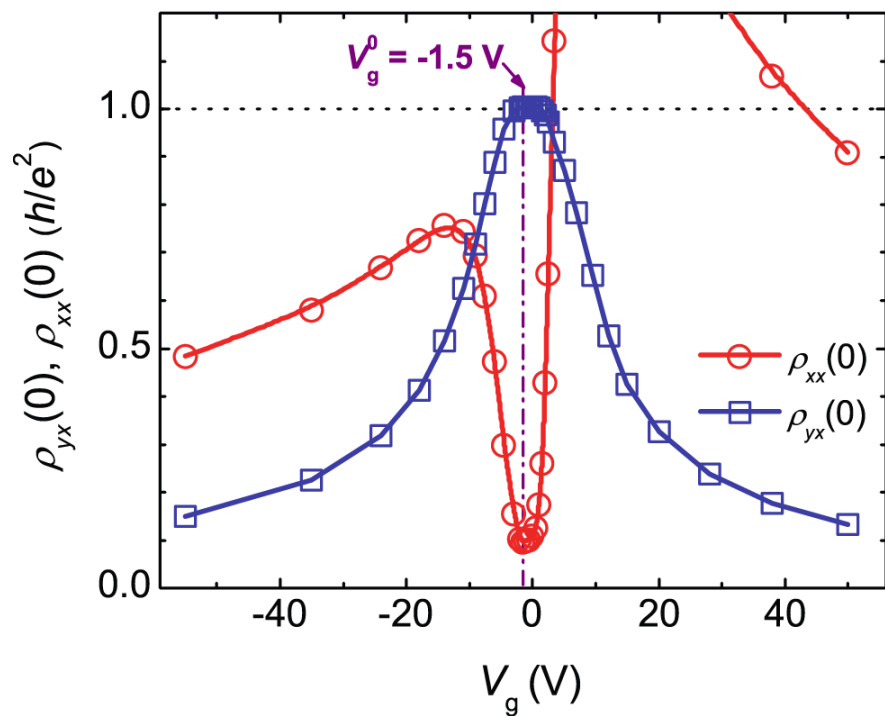
220 V

V_g dependent zero field ρ_{xx} and ρ_{yx}

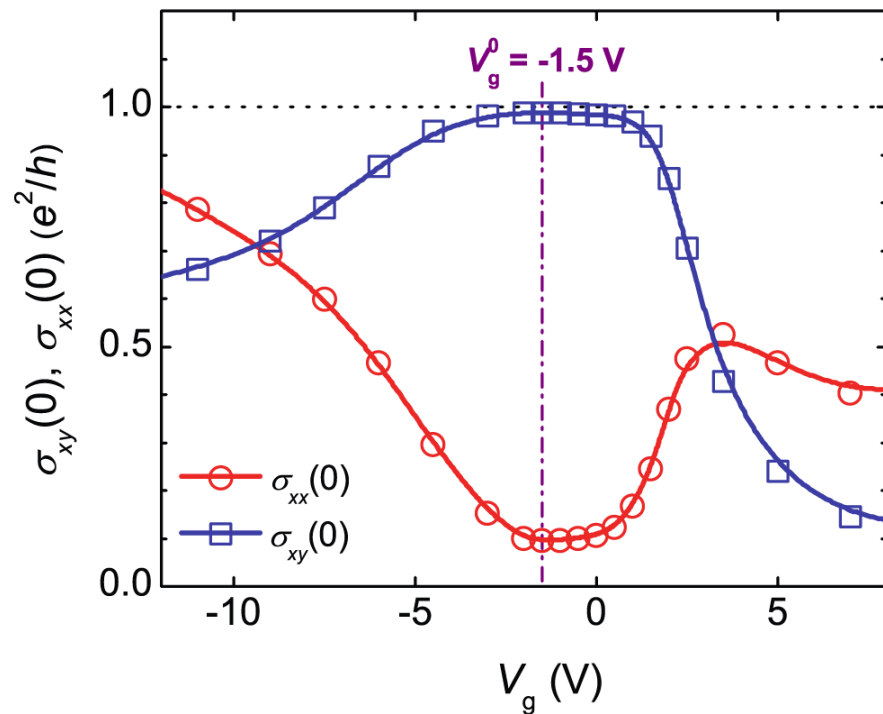
ρ_{xx} dip



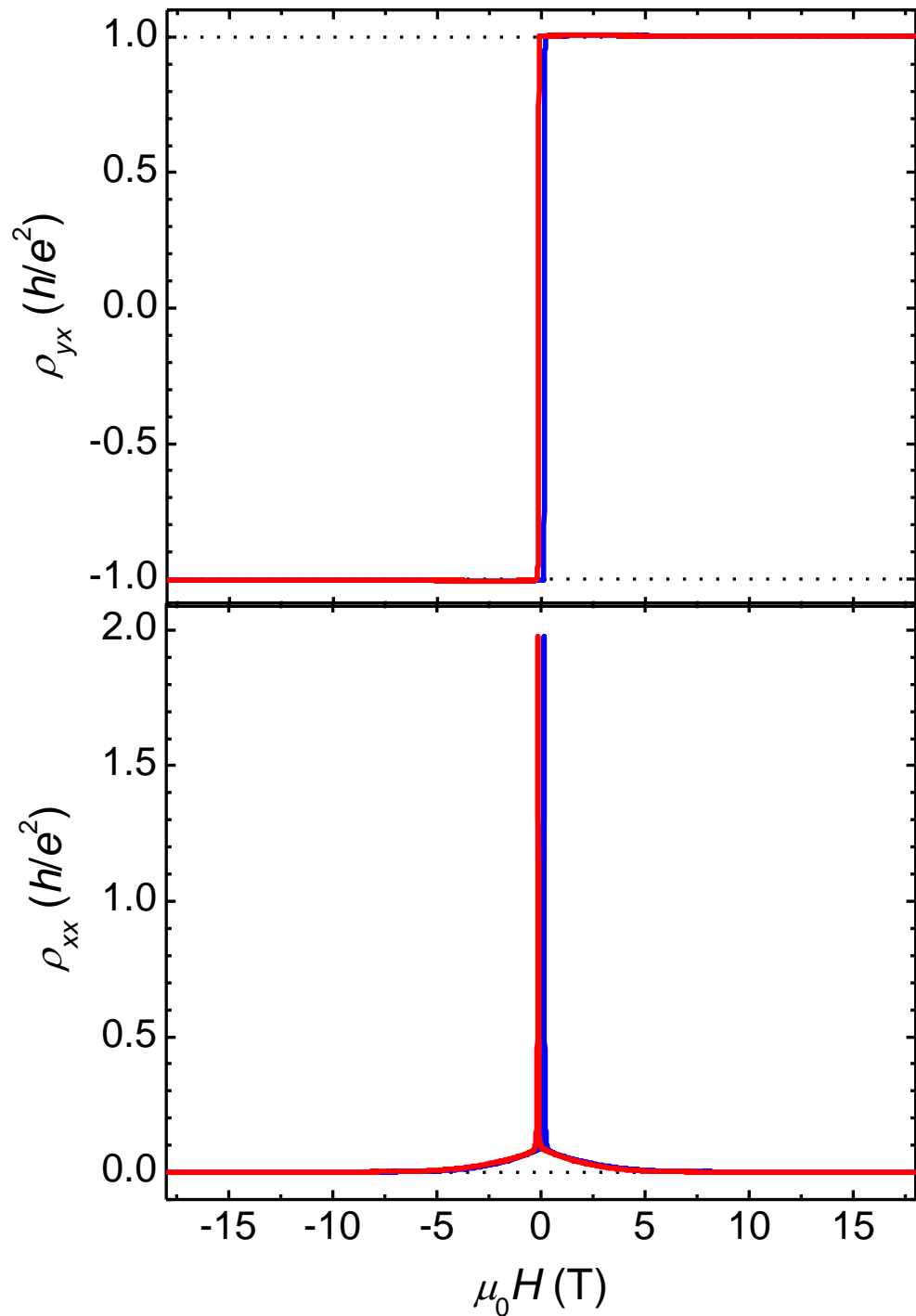
Quantum plateau observed



1 (h/e^2)

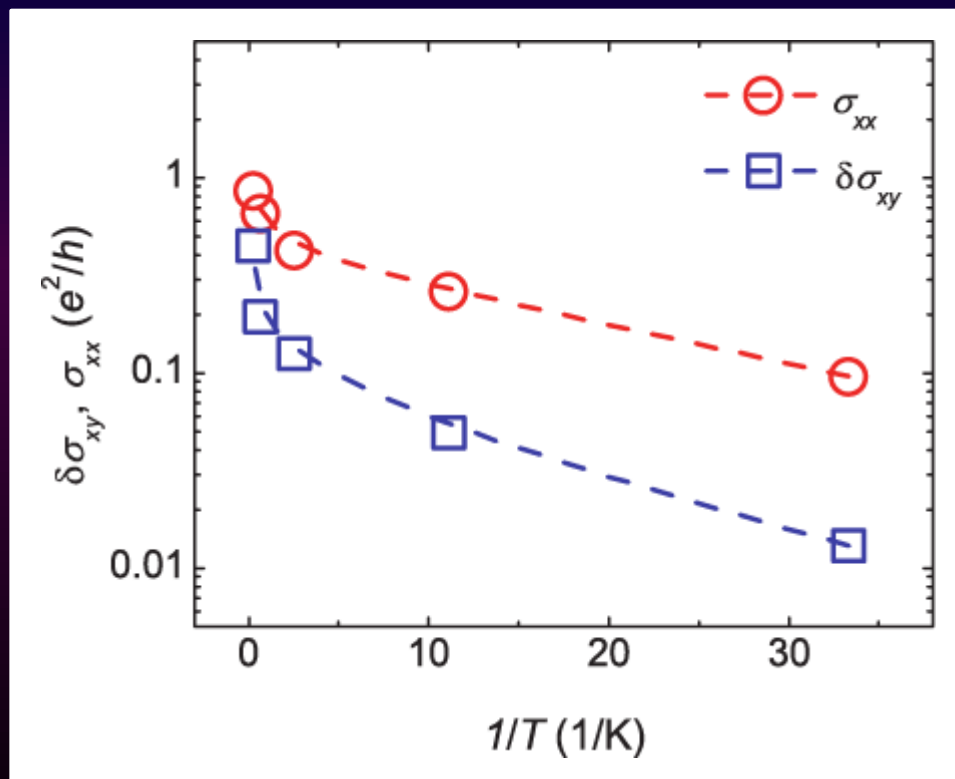
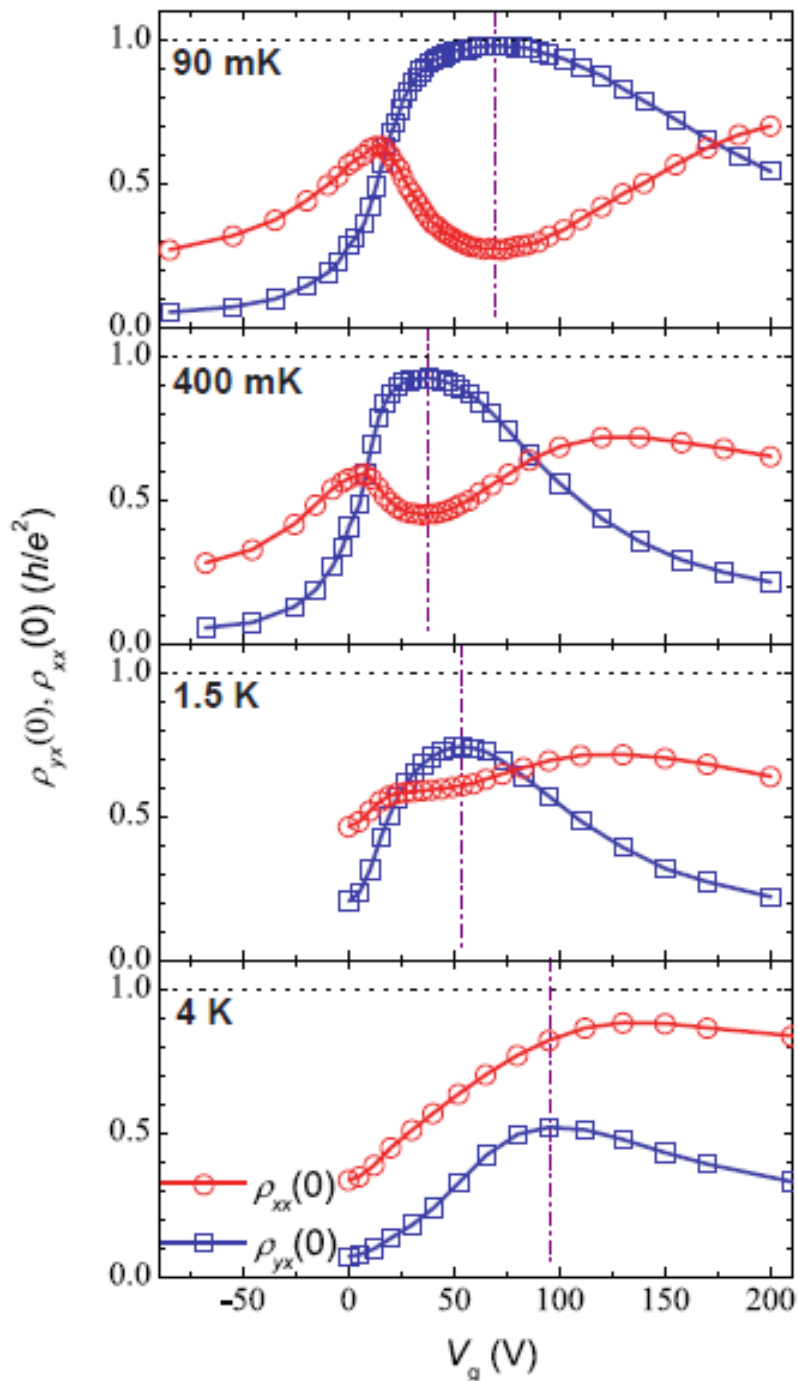


0.99 (e^2/h)

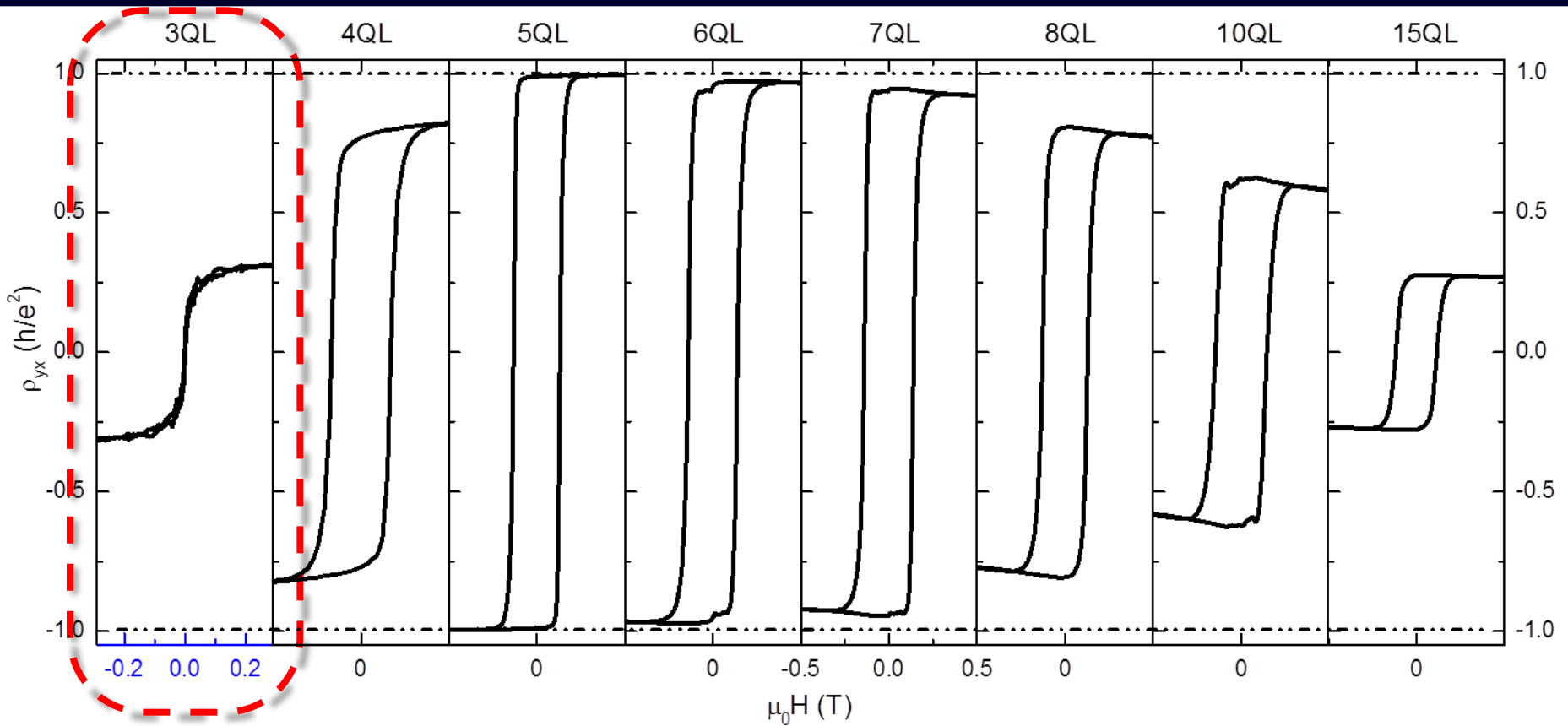


**Dissipationless
transport in
magnetic field
(@ 30 mK)**

Temperature dependence



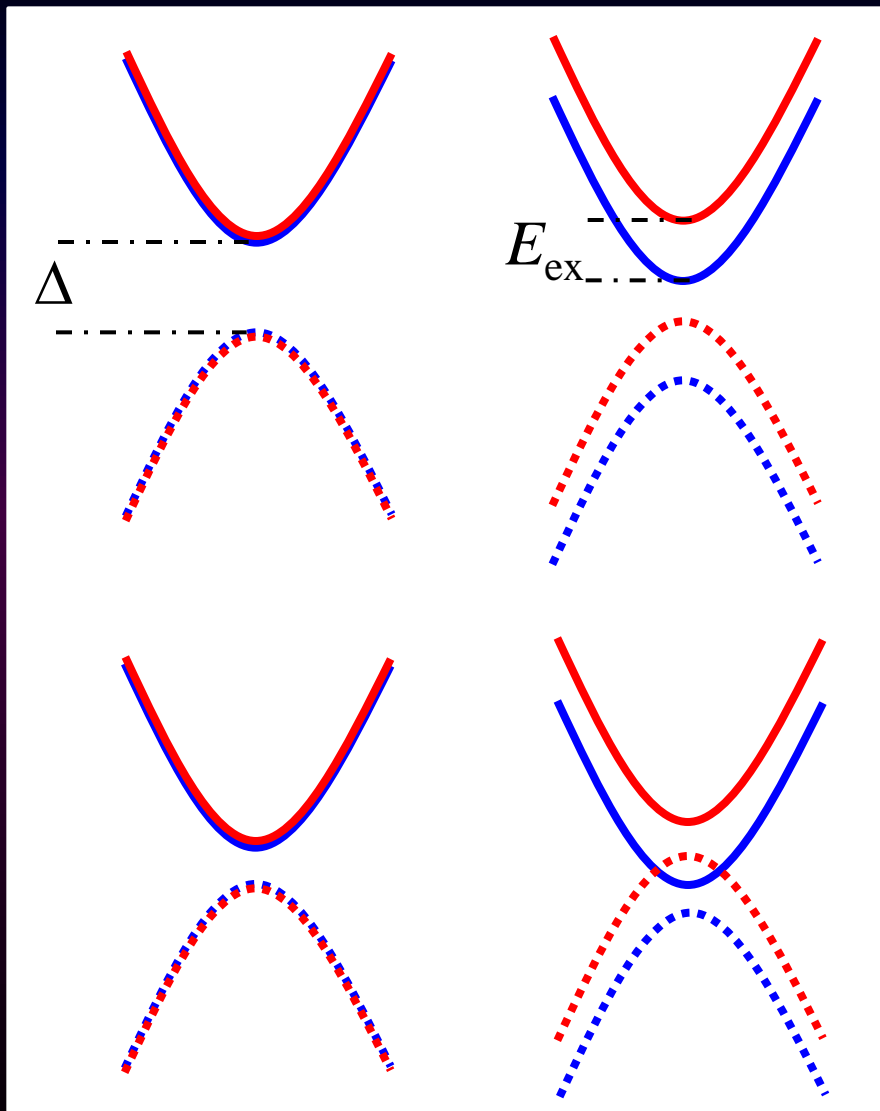
Thickness dependence of the QAHE in Cr-doped $(\text{Bi,Sb})_2\text{Te}_3$ film (low field)



@5 K

@30 mK

Lower thickness limit of a QAH film

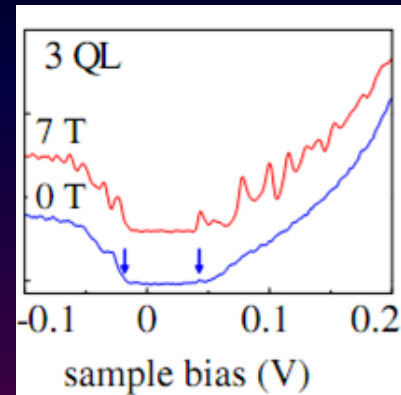


$\Delta > E_{\text{ex}}$:
trivial

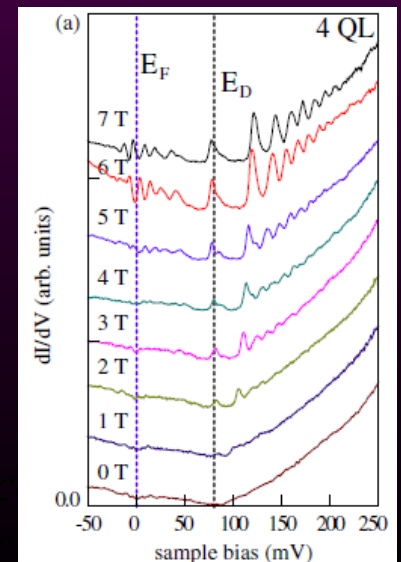
$\Delta < E_{\text{ex}}$:
QAH

Landau levels of
the SSs of Sb_2Te_3
Y. Jiang et al., PRL 2012

3 QL : $\Delta \sim 50 \text{ meV}$

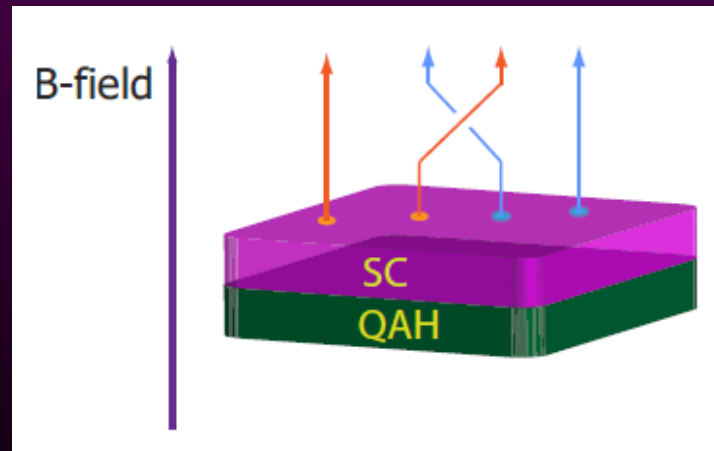


4 QL : $\Delta < 1 \text{ meV}$



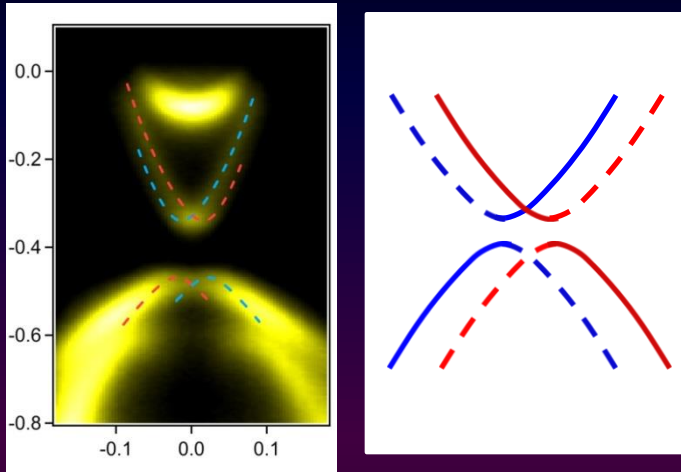
Outlook

- QAHE at higher temperature
- High order QAHE (Jing Wang, PRL 2008)
- QAH-based topological superconductors (X.-L. Qi, PRB 2010)
-

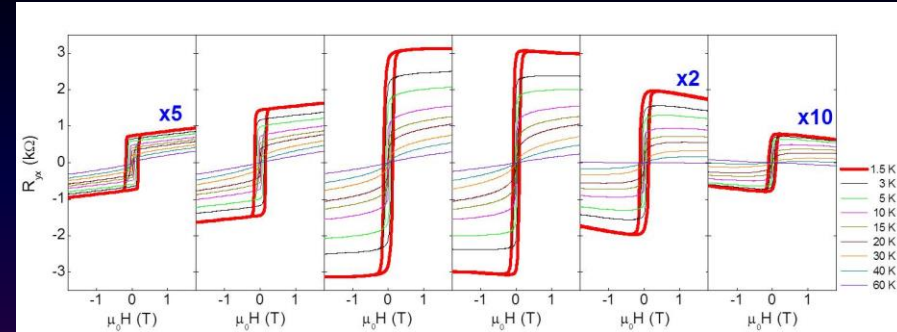


Summary

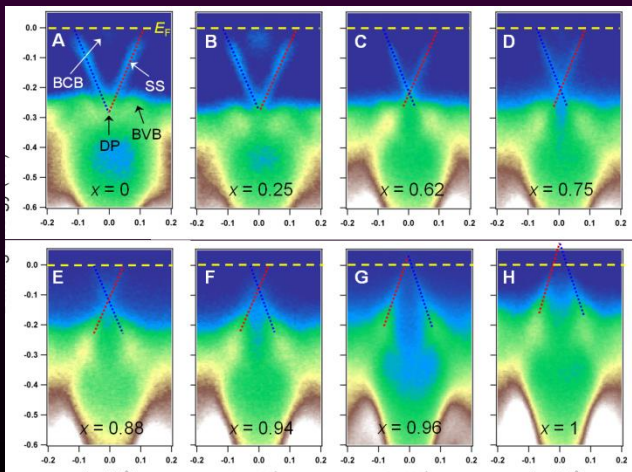
- MBE-grown TI thin films



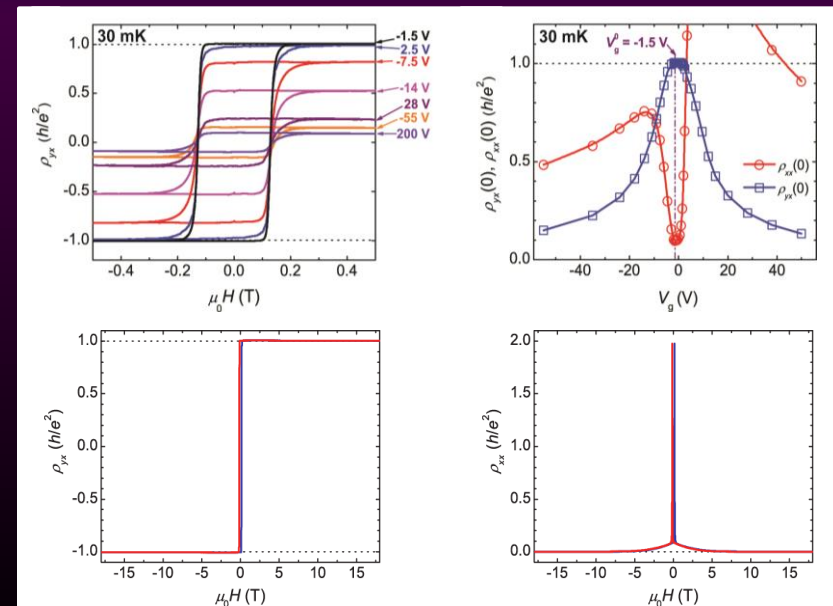
- Magnetically doped TI thin films



- Chemical potential tuning

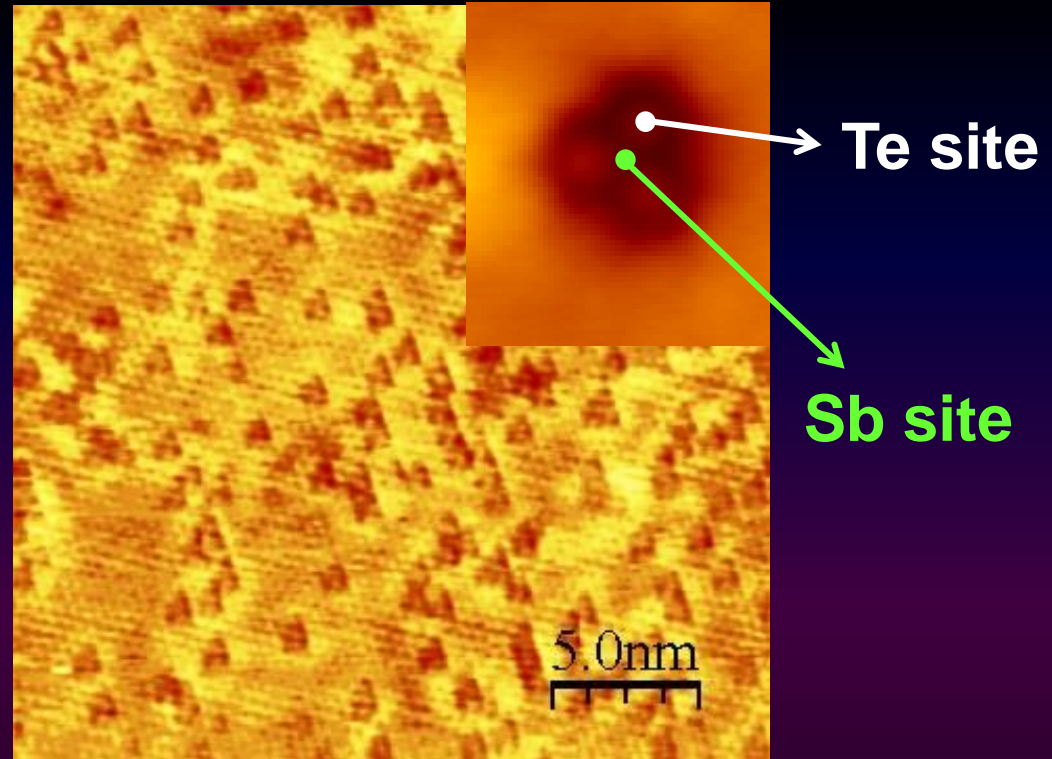
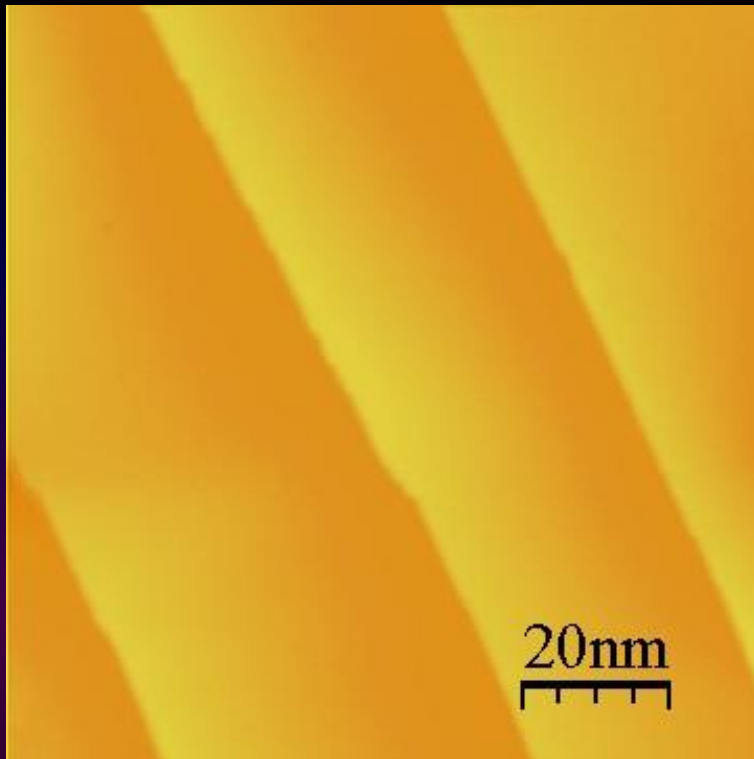


- QAHE



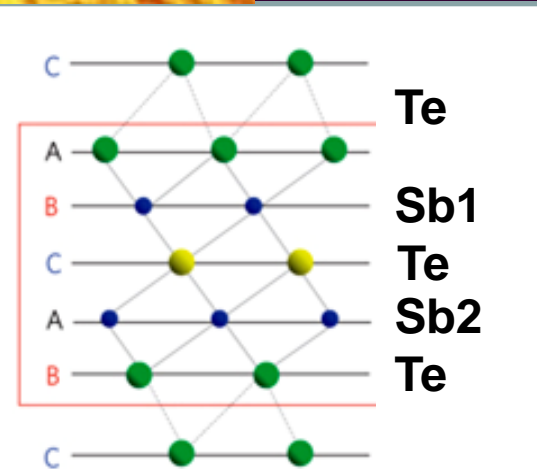
Thank you for your attention !

STM of Cr doped Sb_2Te_3

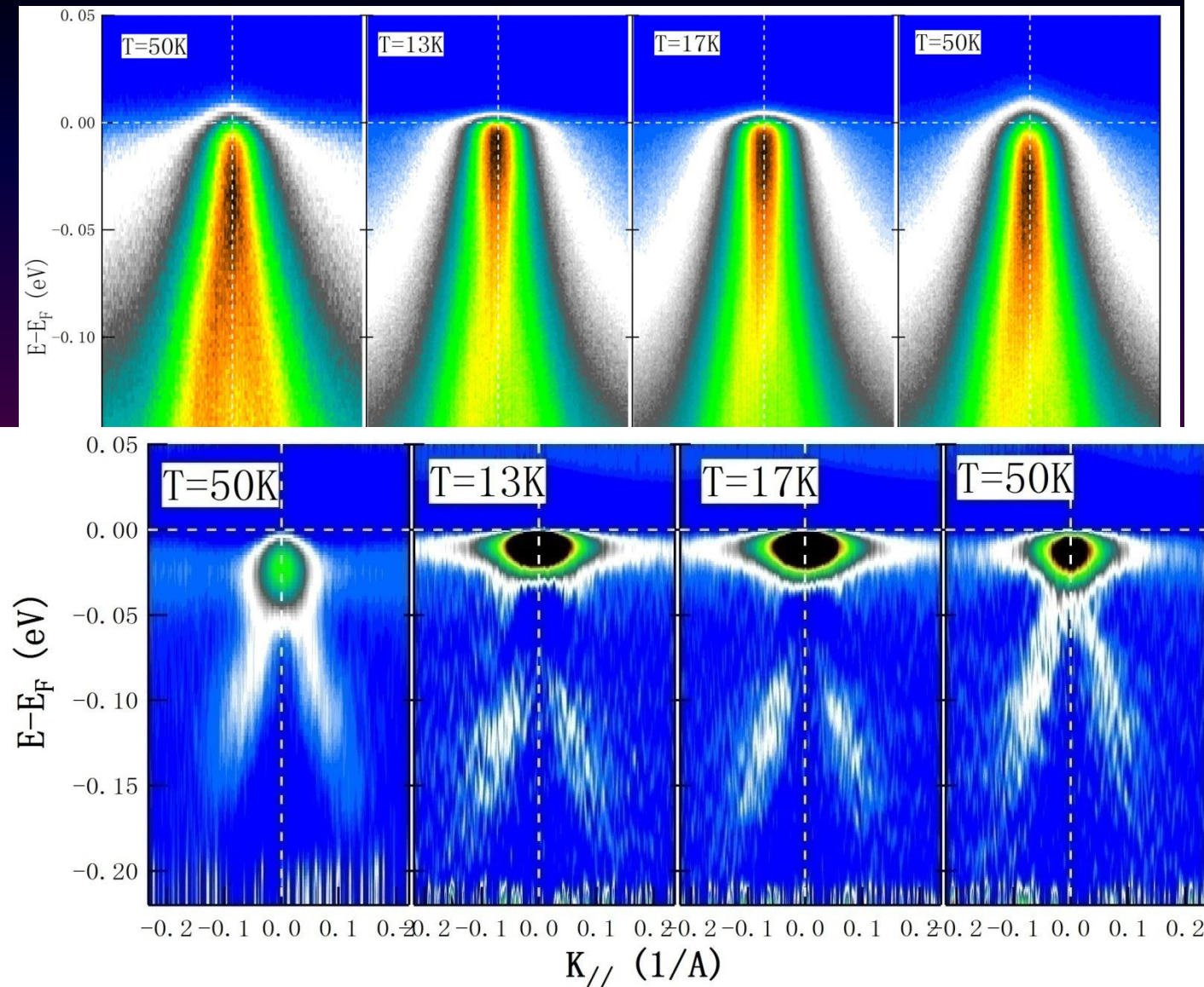
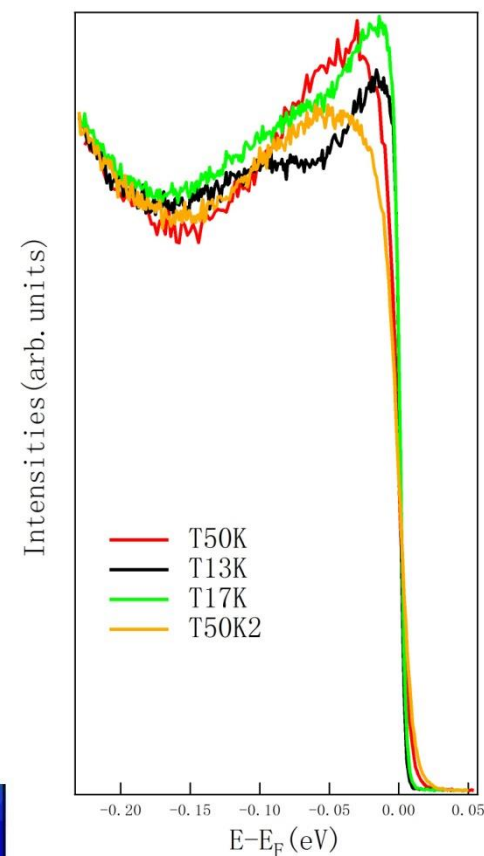


Cr atoms

- **No Clustering**
- **Occupying Sb sites!**



LT-ARPES in Xingjiang Zhou's Lab (IOP)



Cr-doped
 $(\text{Bi}_{0.5}\text{Sb}_{0.5})_2\text{Te}_3$
 $T_c \sim 40\text{K}$